



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)
Andideh, Ebrahim et al.)
U.S. Serial No: 09/436,092) Examiner: McDonald, Shantese L.
Filed: November 8, 1999) Art Unit: 3723
For: POLISH PAD WITH NON-UNIFORM GROOVE DEPTH TO IMPROVE WAFER POLISH RATE	RECE:
UNIFORMITY	RECEIVED NOV 2 5 2003
Commissioner for Patents P. O. Box 1450	TECHNOLOGY CENTER R3700
Alexandria, VA 22313-1450	-700

PRELIMINARY AMENDMENT

Dear Sir:

Serial No.: 09/436,092

Please enter the enclosed Preliminary Amendment and consider the following remarks prior to examination of the above-referenced case.

FIRST CLASS CERTIFICATE OF N	IAILING
I hereby certify that this correspondence is being deposited with sufficient postage in an envelope addressed to the Assistant Cor	
on November 17, 2003	
Date of Deposit	
Teresa Edwards	
Name of Person Mailing Correspondence	X 1
I erroa Edward	November 17, 2002
Signature	Date

Attorney Docket: 042390P3955D